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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of : **Confirmation No. 6163**
Toshikazu TACHIKAWA et al. : Docket No. 2002_0069
Serial No. 10/053,622 : Group Art Unit 1752
Filed January 24, 2002 : Examiner Rosemary E. Ashton

NEGATIVE-WORKING PHOTORESIST
COMPOSITION

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RESPONSE

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In response to the Official Action dated August 6, 2003, please amend the present application as follows:
